

Survey of Materials

Semiconductors

Andriy Zhugayevych

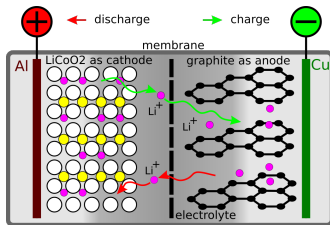
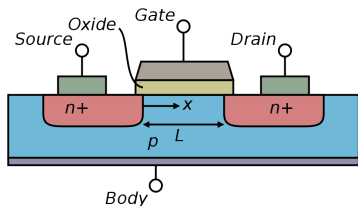
October 8, 2021

Outline

- Introduction: definition and classification
- Key properties
- Applications: solar cells and field-effect transistors
- Classical semiconductors (1 slide)
- Perovskites (1 slide)
- Pnictides and chalcogenides (4 slides + optional slides)
- See separate lecture on organic semiconductors

What is semiconductor: a functional electronic material

- Metals – passive electronic components (wires, electrodes)
- Insulators – passive electronic components (insulators)
- **Semiconductors** – active electronic components (device core)



Electronic devices: transistors, light emitters, solar cells, sensors – any device generating or transforming electronic current

Passive electronic components in devices with electronic-ionic current, such as cathode/anode in rechargeable metal-ion batteries

What is semiconductor: definition by bandgap/conductivity

bandgap	class	electronic conductivity
several eV	insulators	no current because of self-localization
few eV	semiconductors	conductivity is easy to modulate
close to zero	semimetals	overlapping bands \implies similar to doped semiconductors
close to zero	strongly correlated	charge density fluctuations can close/open pseudogap
negative	simple metals	invariable conductivity due to large density of states at Fermi-level

Key functional properties of semiconductors

Current density $j = \mu \cdot n \cdot e\mathcal{E}$

- high charge carrier mobility
- controllable charge carrier concentration

Factors influencing mobility

Current density $j = \mu \cdot n \cdot e\mathcal{E}$

Mobility $v = \mu\mathcal{E}$

Zero-field mobility $\mu = \frac{e}{T}D$

Free charge carriers

Drude formula

$$\mu = \frac{e\tau_{\text{scattering}}}{m_{\text{effective}}}$$

Localized charge carriers

Hopping

$$\mu = \frac{2\pi e}{\hbar} f \cdot (aV)^2 \frac{J}{T}$$

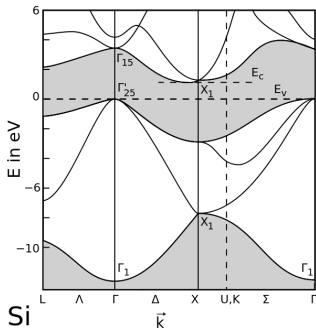
* Purely **electronic** and **electron-phonon** interaction terms are factorized

Scattering (or localization) mechanisms:

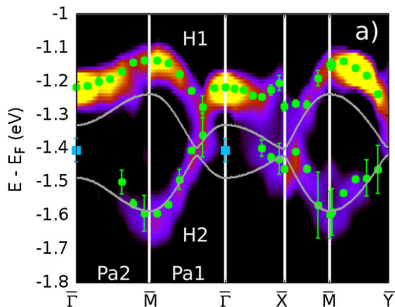
- dynamic lattice defects (phonons, intramolecular vibrations)
- extrinsic disorder: from lattice defects to mesoscopic inhomogeneity (grain boundaries, interfaces)
- carrier-carrier interaction

f is lattice form-factor, a is lattice spacing, V is electronic inter-site coupling, aV is hopping amplitude, J is spectral overlap

Need high bandwidth and low effective mass



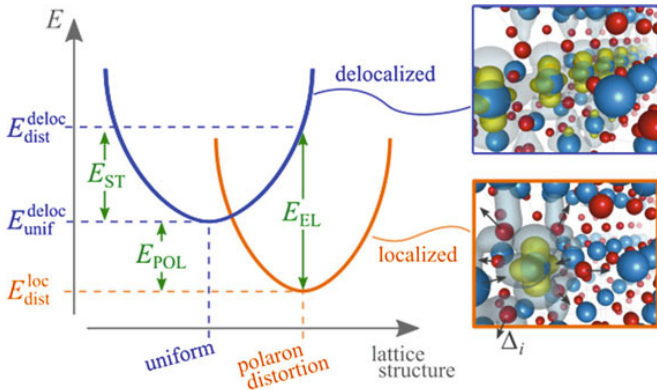
weak e-p interaction
⇒ free charge carriers
scattered by phonons



strong e-p interaction
⇒ mobile or
localized polarons

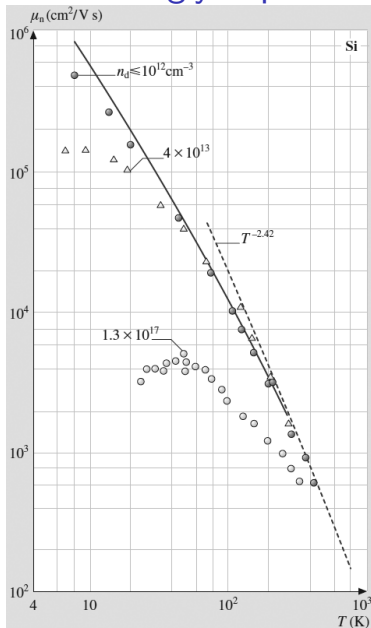
Polarons and localization

Free charge carriers – large polarons – mobile small polarons – localized charge carriers



M Reticcioli *et al*, Small Polarons in Transition Metal Oxides (Springer, 2020)

Scattering by phonons strongly depends on temperature



Room temperature mobility in different semiconductors

material	$\mu_n \left(\frac{\text{cm}^2}{\text{V}\cdot\text{s}} \right)$	$\mu_p \left(\frac{\text{cm}^2}{\text{V}\cdot\text{s}} \right)$
AlGaAs/GaAs 2DEG at low T	10^7	
graphene at low T	10^5	
InAs	10^4	
Ge	3800	1800
GaAs	3000	400
diamond	2000	2000
monocrystalline Si	1400	400
polycrystalline Si	100	
ZnS	100	40
best organic crystals	10	10
amorphous Si	1	
best organic polymers		0.1
solid electrolytes, water	10^{-3}	10^{-3}

Changing charge carrier concentration

- charge carrier injection
- doping (intentional and unintentional)
- photoexcitation
- field effect

Doping

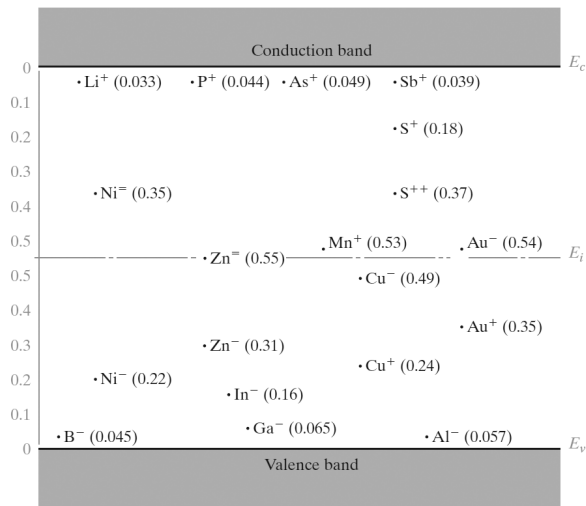
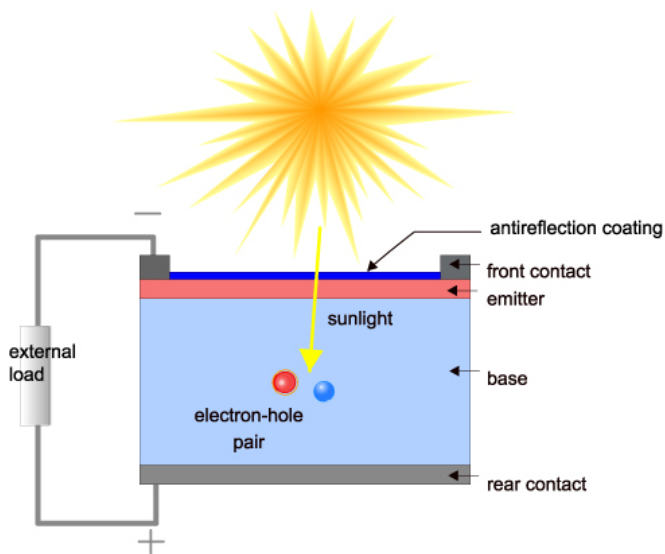


Figure 4-9
Energy levels of impurities in Si. The energies are measured from the nearest band edge (E_v or E_c); donor levels are designated by a plus sign and acceptors by a minus sign.

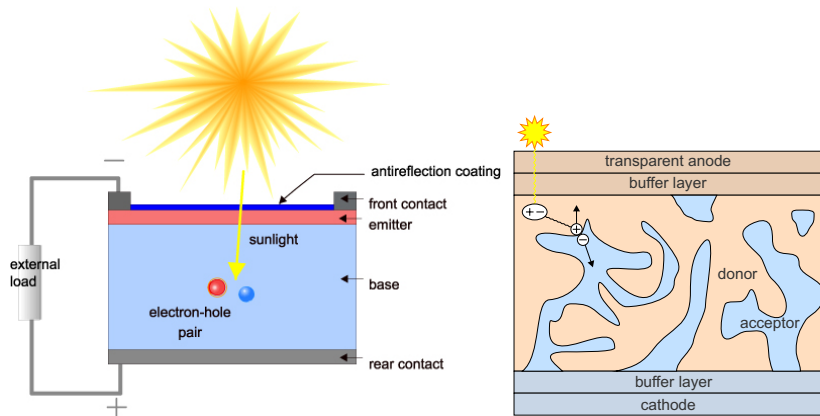
⁴References: S. M. Sze and J. C. Irvin, "Resistivity, Mobility, and Impurity Levels in GaAs, Ge and Si at 300 K," *Solid State Electronics*, vol. 11, pp. 599-602 (June 1968); E. Schibli and A. G. Milnes, "Deep Impurities in Silicon," *Materials Science and Engineering*, vol. 2, pp. 173-180 (1967).

Photoexcitation



Either bound (Frenkel exciton) or free (or Wannier–Mott exciton) electron and holes depending on dielectric constant

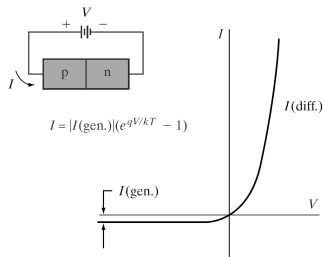
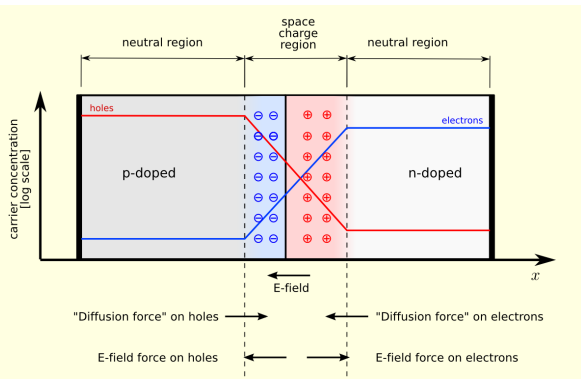
Photovoltaic effect and solar cells



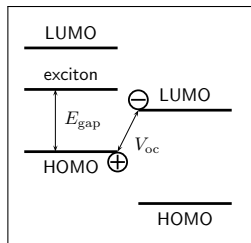
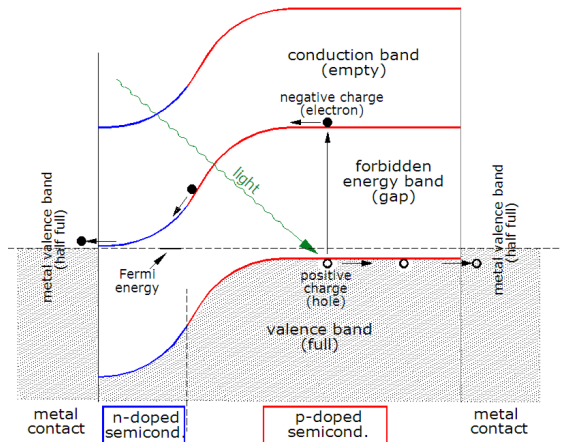
Challenge:

Efficient charge separation at full light absorption and high voltage

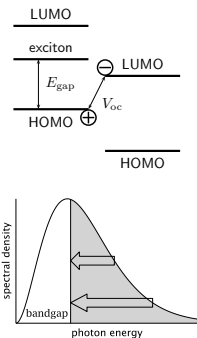
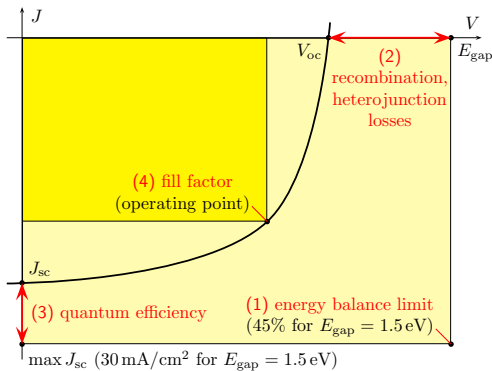
p-n junction and Shockley diode equation



Photovoltaic effect: p-n junction and heterojunction



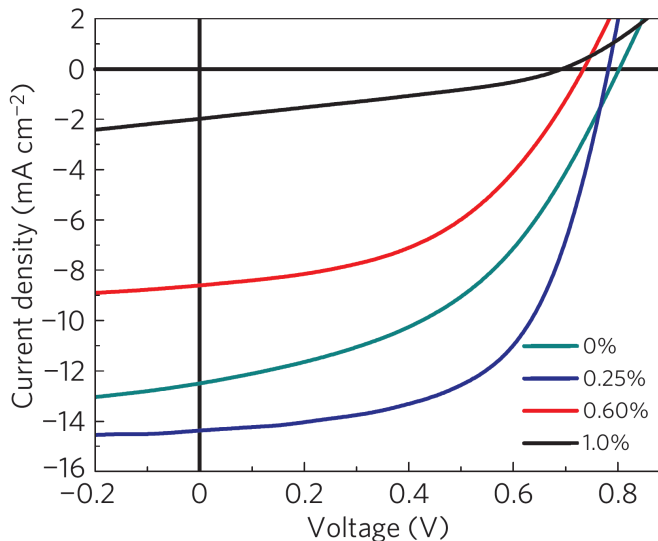
Power conversion efficiency (PCE): main factors



$$\eta = \frac{J_{\text{sc}} \times V_{\text{oc}} \times \text{FF}}{P_{\text{in}}} \equiv \eta_{\text{abs}}(E_{\text{g}}) \times \frac{eV_{\text{oc}}}{E_{\text{g}}} \times \frac{J_{\text{sc}}}{J_{\text{sc}}^{\text{max}}(E_{\text{g}})} \times \text{FF}$$

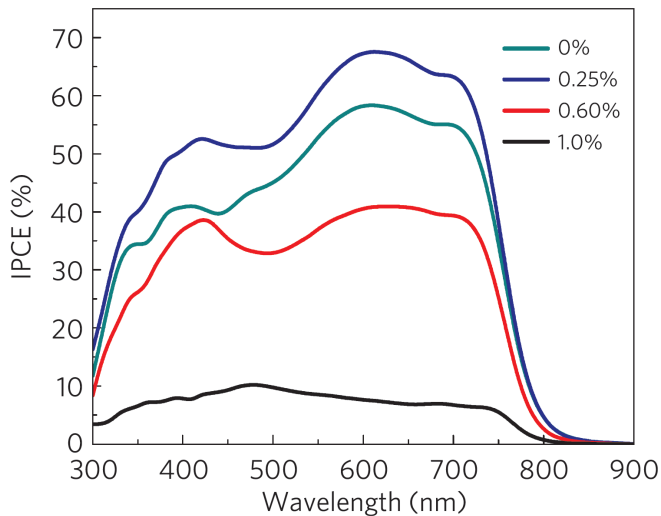
V_{oc} – open-circuit voltage, J_{sc} – short-circuit current, E_{g} – bandgap

Power conversion efficiency: Fill factor

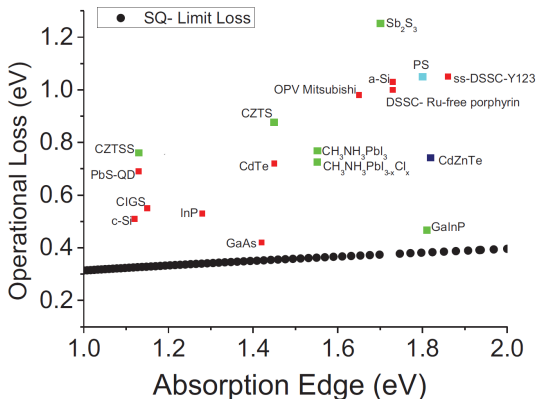
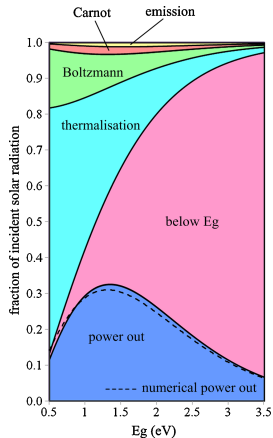


Power conversion efficiency: Quantum efficiency

(IPCE = Incident Photon to Current Efficiency)



Power conversion efficiency: Shockley–Queisser limit



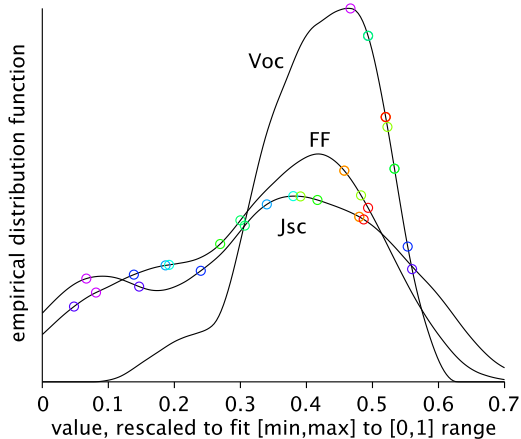
$$eV_{oc} = E_g \left(1 - \frac{T}{T_{in}} \right) - kT \ln \frac{\Omega_{out}}{\Omega_{in}} + kT \ln \frac{\gamma(E_g, T_{in})}{\gamma(E_g, T)} + kT \ln \eta_{lum}$$

Ref.: J App Phys 32, 510 (1961), Adv Mater 26, 1622 (2014),
 Prog Photovolt Res Appl 19, 286 (2011)

Power conversion efficiency: examples

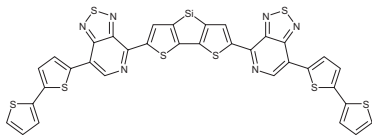
		OPV	Si	GaAs
Energy balance limit, $\eta_{\text{abs}}(E_g)$		0.5	0.49	0.45
Recombination losses, eV_{oc}/E_g	×	0.6	0.63	0.79
Quantum efficiency, $J_{\text{sc}}/J_{\text{sc}}^{\text{max}}(E_g)$	×	0.6	0.97	0.93
Fill Factor, $\max JV/J_{\text{sc}} V_{\text{oc}}$	×	0.8	0.83	0.87
Power conversion efficiency	=	14%	25%	29%

Distribution of V_{OC} , J_{SC} , FF

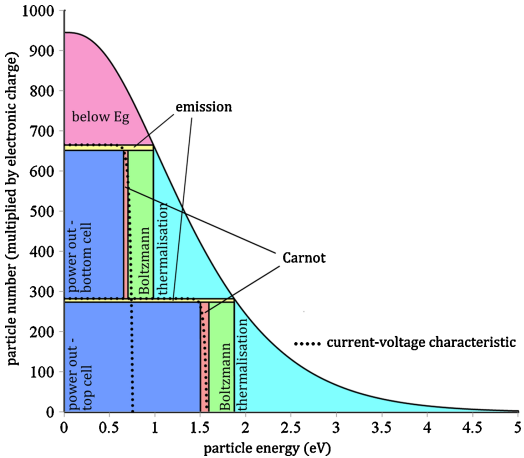
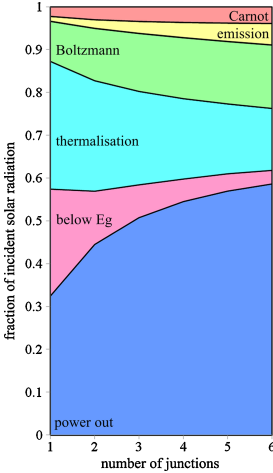


– Empirical distribution over 67 OPVs is provided by J. McClean (Clean Energy Project)
<http://cleanenergy.harvard.edu>

○ Dots correspond to refinement of one system, up to 7% PCE (Nature Mater 11, 44 (2012) JACS 134, 16597 (2012))

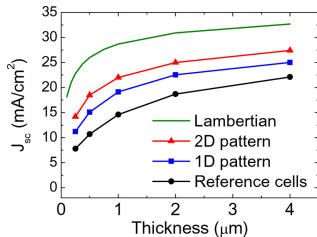
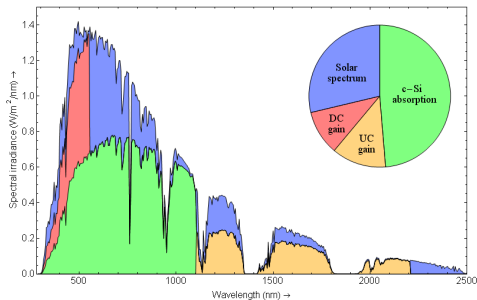
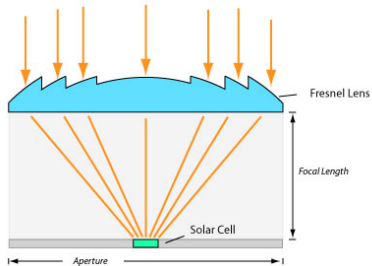
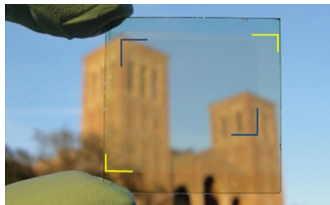


Multijunction cells

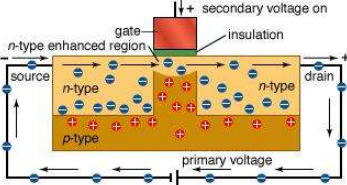
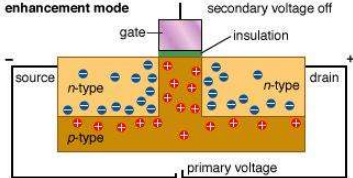
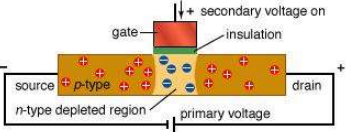
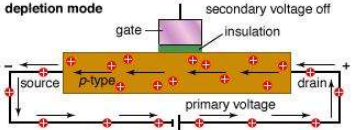


Technology: other tricks

(transparent, concentrated, up-down conversion, improved optics)



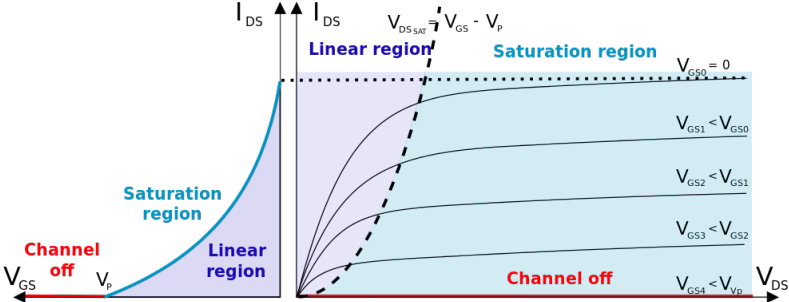
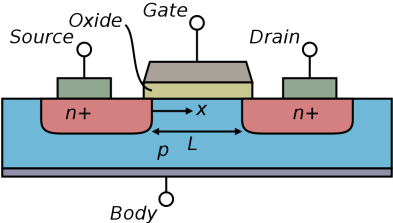
Field effect



© 2004 Encyclopædia Britannica, Inc.

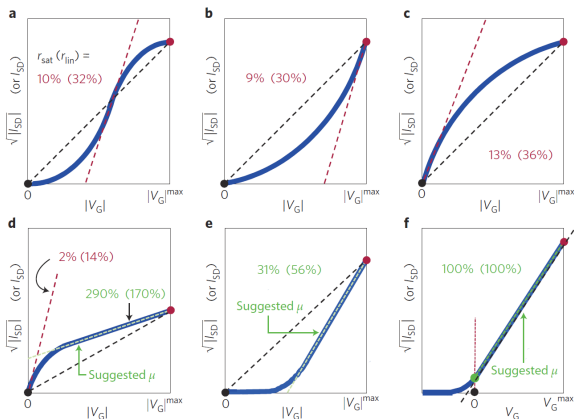
Field effect transistor

(depletion mode)



Field effect transistor: measuring mobility

H H Choi, K Cho, C D Frisbie, H Sirringhaus, V Podzorov, Nat Mater 17, 2 (2018) – pdf



In linear regime $\mu = \frac{L/W}{CV_{SD}} \frac{dI_{SD}}{dV_G}$, where L/W is channel form-factor (length/width) and C is gate-channel capacitance per unit area¹

¹Should be measured, if not possible, estimate as $\epsilon\epsilon_0/d$

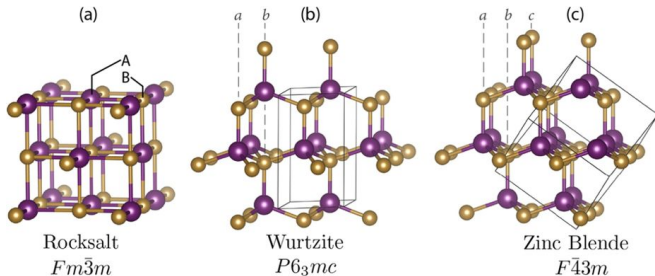
Other functional properties of semiconductors

- high charge carrier mobility
- controllable charge carrier concentration
- FET: high saturation velocity
- FET: high on/off ratio
- Solar/PD: strong light absorption (high IPCE)
- LED: efficient light emission (high EQE)
- Solar/LED: right bandgap (or use dopants)

“Classical” semiconductors

Average valence 4 compounds:

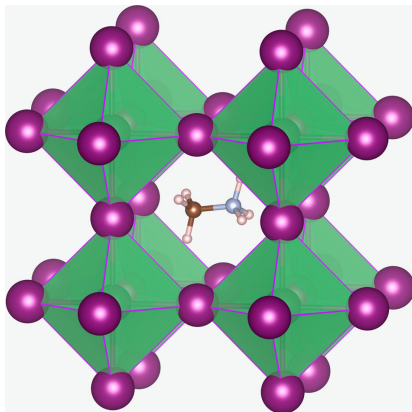
- IV (Si)
- III+V (GaAs)
- II+VI (ZnS)
- I+VII (AgI)
- II+IV+V (CdSnAs₂)
- I+III+VI (CIGS=CuIn_{1-x}Ga_xSe₂)



- Prefer mostly tetrahedral lattices: zincblende or wurtzite
- Wide-gap ionic compounds might form rocksalt lattice
- Also heterostructures and nanostructures

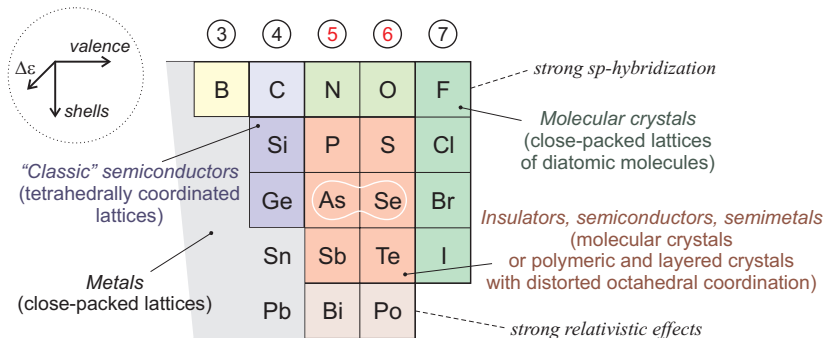
Ionic “average-valence-4” semiconductors

Semiconducting halide perovskites: I+II+VII or ABX₃



Ionic \implies solution processable

Pnictide and chalcogenide semiconductors



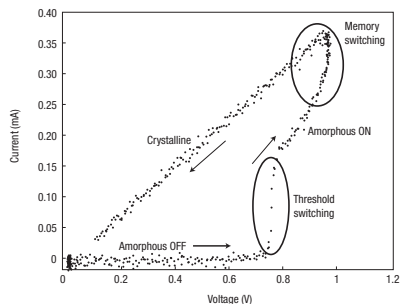
- Pnictogens: P, As, Sb
- Chalcogens: S, Se, Te
- Average valence 5-6
- Not in the class: transition metal pnictides and chalcogenides

Key properties

- Polymorphism with high contrast in electronic properties:
crystalline As is metal, amorphous As is insulator
- Photo- and current-induced reversible structural changes:
phase change memory alloys
- Low covalent connectivity (2-3), strong noncovalent bonding
1D, 2D, and “sandwich” structures, nonstoichiometric alloys

Application: Phase change memory

Polymorphism with high contrast in electronic properties
+ fast transition between the two phases

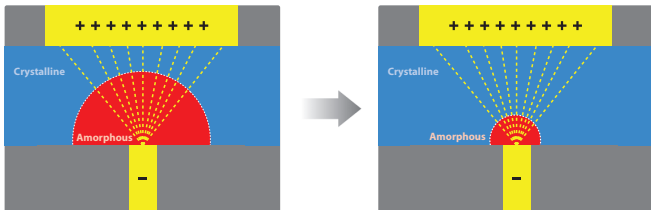
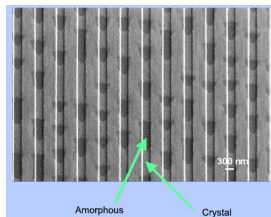


Nature Mater 6, 824 (2007)

Ge₂Sb₂Te₅

- DVD-RAM and DVD-RW
- PCM or PRAM
non-volatile random-access
memory

Phase change memory: historical perspective



Phase change memory (PCM, PRAM) – 60-year evolution:

- 1) research \implies reviews 1955, patent 1966, DVD 1997
- 2) research \implies reviews 2000s, PRAM prototypes 2005

Phase change memory: engineering perspective

3D XPoint non-volatile memory (2015)

3D XPoint™ Technology: An Innovative, High-Density Design

Cross Point Structure

Perpendicular wires connect submicroscopic columns. An individual memory cell can be addressed by selecting its top and bottom wire.

Non-Volatile

3D XPoint™ Technology is non-volatile—which means your data doesn't go away when your power goes away—making it a great choice for storage.

High Endurance

Unlike other storage memory technologies, 3D XPoint™ Technology is not significantly impacted by the number of write cycles it can endure, making it more durable.

Stackable

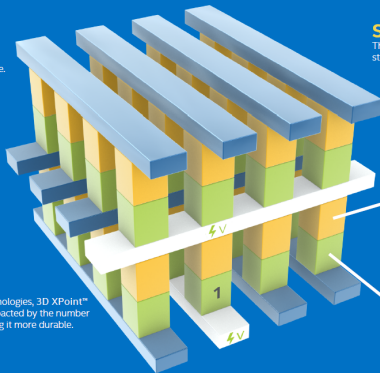
These thin layers of memory can be stacked to further boost density.

Selector

Whereas DRAM requires a transistor at each memory cell—making it big and expensive—the amount of voltage sent to each 3D XPoint™ Technology selector enables its memory cell to be written to or read without requiring a transistor.

Memory Cell

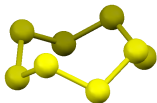
Each memory cell can store a single bit of data.



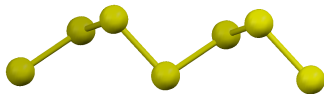
Examples and applications summary

- $\text{Ge}_2\text{Sb}_2\text{Te}_5$ and AgInSbTe – phase-change materials
- materials for “3D carving” for photonics and optoelectronics
- Se was commonly used as photoconductor in photocopiers
- Bi_2Te_3 – one of the best performing thermoelectrics
(strictly speaking not in the class)

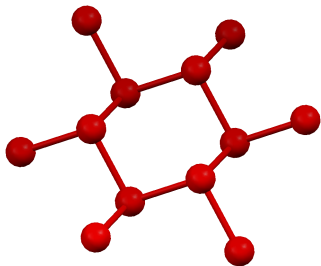
Structure: diversity and polymorphism



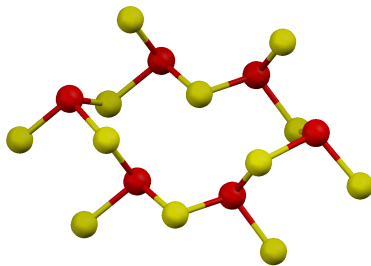
α -S
(molecular crystal)



Se, Te, high-pressure S
(polymeric crystal)



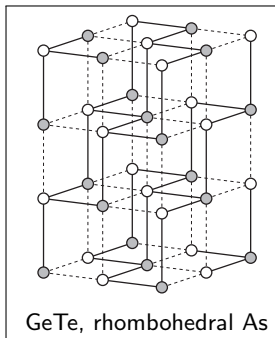
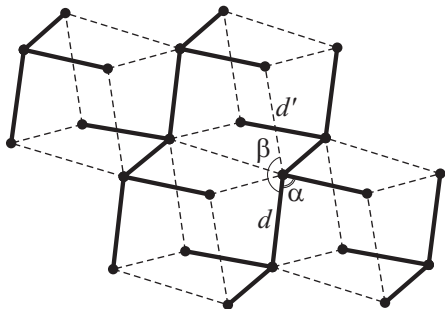
As, Sb, Bi, high-pressure P
(layered crystal)



As_2S_3
(layered crystal)

Is there a common structural motif?

Structural motif: distorted octahedral coordination

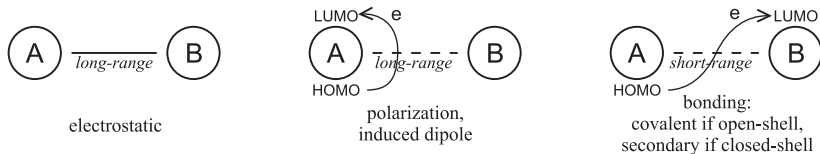


- Right-angled geometry: $90^\circ \lesssim \alpha < 109^\circ$
- Secondary $pp\sigma$ bonding: $d'_{AB} < r_A^{\text{vdW}} + r_B^{\text{vdW}}$
- Can be called “back-bonding”: $\beta > 160^\circ$
- Trans-influence: $d_{AB} > r_A^{\text{cov}} + r_B^{\text{cov}}$

But

- some bonds may be missing for elements of group VI and VII
- competing tetrahedral coordination for elements of group IV

What is secondary bonding?



$$\begin{aligned}
 E_{\text{bind}} &= \Delta E_{\text{nuc}} + \langle AB | H_{\text{int}} | AB \rangle \\
 &+ \sum_{\text{exc}} \frac{\langle AB | H_{\text{int}} | A^{\text{exc}} B^{\text{exc}} \rangle^2}{E_A + E_B - E_A^{\text{exc}} - E_B^{\text{exc}}} \\
 &+ \sum_{\pm \text{states}} \frac{\langle AB | H_{\text{int}} | A^{\pm} B^{\mp} \rangle^2}{E_A + E_B - E_A^{\pm} - E_B^{\mp}} \\
 \implies E_{\text{sec.bond}} &= \frac{2t_{12}^2}{E_1^{\text{ion}} - E_2^{\text{aff}}} \equiv \frac{E_1^{\text{ion}} - E_2^{\text{aff}}}{2} \times \langle \text{bond-order} \rangle
 \end{aligned}$$

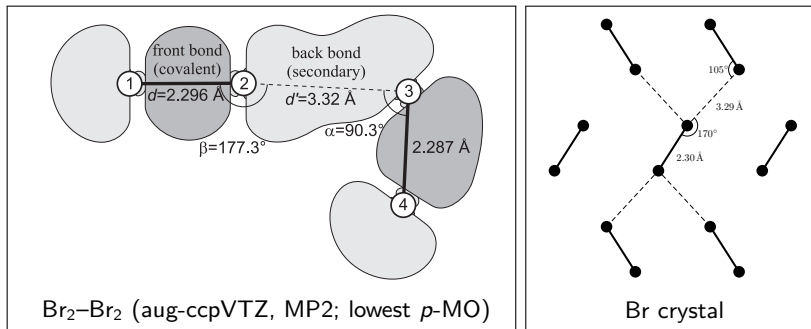
Examples of secondary bonding

Structural signatures of secondary bonding:

- Orbital overlap: $d'_{AB} < r_A^{\text{vdW}} + r_B^{\text{vdW}}$
- Trans-influence: $d_{AB} > r_A^{\text{cov}} + r_B^{\text{cov}}$
- Alignment with respect to the covalent bond

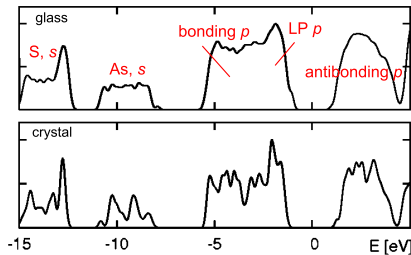
		donor	acceptor	t'	$E^{\text{ion}} - E^{\text{aff}}$
backbonding	α -As	$pp\sigma$	$pp\sigma^*$	$t'_{pp\sigma}$	$2t_{pp\sigma}$
backbonding	Br ₂ -Br ₂	$pp\sigma$	$p\text{-LP}$	$t'_{pp\sigma}$	$t_{pp\sigma}$
π -conjugation	poly-CH	$pp\pi$	$pp\pi^*$	$t'_{pp\pi}$	$2t_{pp\pi}$
π -backbonding	Cr(CO) ₆	$pp\pi$	d	$t'_{pp\pi}$	$t_{pp\pi} + \Delta\epsilon_{pd}$
	Be ₂	s	p	t_{sp}	$\Delta\epsilon_{sp}$
hydrogen bond	H-A	s	A		
halogen bond	F-D	D	p		

Examples of secondary bonding: halogen molecules

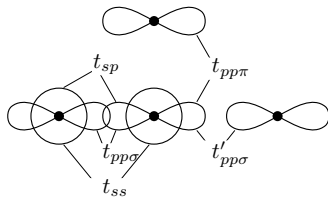


- Right-angled coordination: $\alpha \approx 90^\circ$
- Secondary bonding: $d' < 2r_{\text{vdW}}$ and $\beta \approx 180^\circ$
- Trans-influence: $d > 2r_{\text{cov}}$ (left molecule is elongated)
- Dimer and crystal have principally the same geometry

Electronic structure: degeneracy of the covalent network



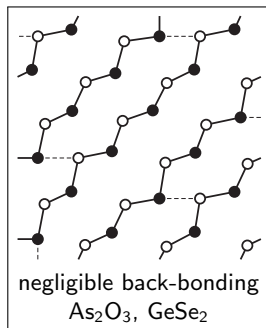
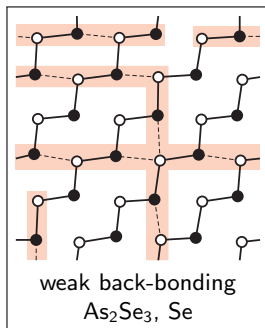
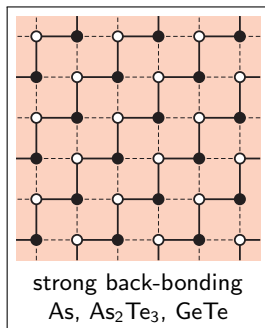
EDOS for As_2S_3 (Simdyankin, Elliott, 2004)



Transfer integrals

- s-orbitals do not contribute to bonding
 - it is the network of $pp\sigma$ -bonds ($pp\sigma$ -network)
- $pp\sigma$ -bonds themselves do not form 3D solid
 - the structure is determined by the balance of
 - secondary bonding $t_{pp\sigma}^2/2t_{pp\sigma}$
 - hybridization or sp -interaction $t_{sp}^2/(\epsilon_p - \epsilon_s - t_{pp\sigma})$
 - $pp\pi$ -interaction (usually small) $t_{pp\pi}^2/2t_{pp\sigma}$

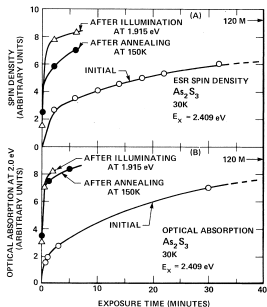
Structure: three classes of $pp\sigma$ -networks



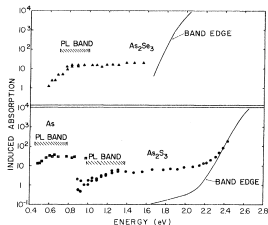
How to get this picture: Project Fock matrix onto valence p -orbitals and mark all the resulting elements $\gtrsim 0.5t_{pp\sigma}$

Photoinduced phenomena: experiment

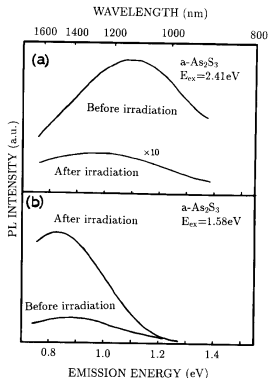
ESR and subgap absorption
Phys Rev Lett 44, 803 (1980)



Midgap absorption
Phys Rev B 15, 2278 (1977)

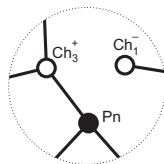
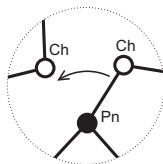
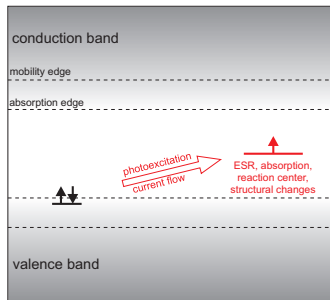


New PL after bandgap irradiation
J Non-Cryst Solids 114, 88 (1989)



- 5% volume expansion [J Optoelectronics Adv Mater 8, 2058 (2006)]

Photoinduced phenomena: theory



1. Midgap states originate from coordination defects whose ground state is charged (Street, Mott, 1975)
2. They pair up into positively charged overcoordinated atom and negatively charged undercoordinated – VAP (Kastner, Adler, Fritzsche, 1976; Pollard, Joannopoulos, 1979)
3. Defects can move and be created by bond switching, which is the underlying mechanism for photoinduced phenomena

What is the microscopic mechanism for such an efficient bond switching?

Challenges

- Find better materials for phase change memory
- Improve device architecture for phase change memory
- How to drive structural changes nonthermally
- Lack of microscopic description of photoinduced changes
- Lack of quantitative prediction of photoinduced changes
- Limited use of pnictides and chalcogenides

Research at Skoltech

Theory:

- **Vasili Perebeinos** (now at Buffalo U) – classical semiconductors
- **Xavier Gonze** (also at UCLouvain) – classical semiconductors
- **Sergei Tretiak** (also at LANL) – perovskites, organic, quantum dots
- **Sergey Levchenko** – oxides
- **Andriy Zhugayevych** – organic, pnictides/chalcogenides

Experiment:

- **Keith Stevenson** – organic, perovskites
- **Pavel Troshin** (now at IPCP RAS) – organic, perovskites
- **Albert Nasibulin** – carbon nanotubes
- **CPQM CREI** – photonics and optoelectronics

Resources

- Wikipedia
- Callister chapter 18.(1-15)
- Ashcroft chapters 28-29
- Kittel chapter 8
- **Textbooks** (see Topical references on semiconductors)
- Perovskites: **References**
- Pnictides/chalcogenides: **References**
- Organic: **References**
 - ▶ Separate lecture **here**
 - ▶ Separate course in Term 3
 - ▶ A Koehler, H Bassler, Electronic Processes in Organic Semiconductors: An Introduction (Wiley, 2015) *in library*
 - ▶ Albert Nasibulin's lecture on carbon nanotubes in Canvas